

Hyperabrupt SrTiO₃ Varactors for Sensitive Reflectometry of Quantum Dots

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Cryogenic hyperabrupt strontium titanate varactors for sensitive reflectometry of quantum dots

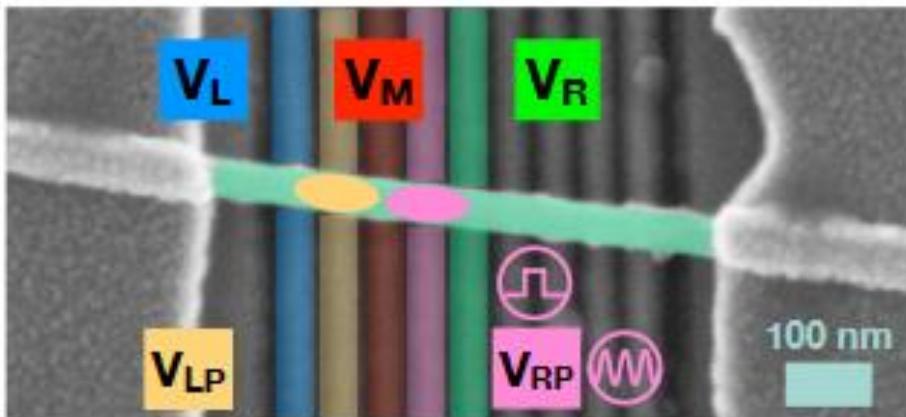
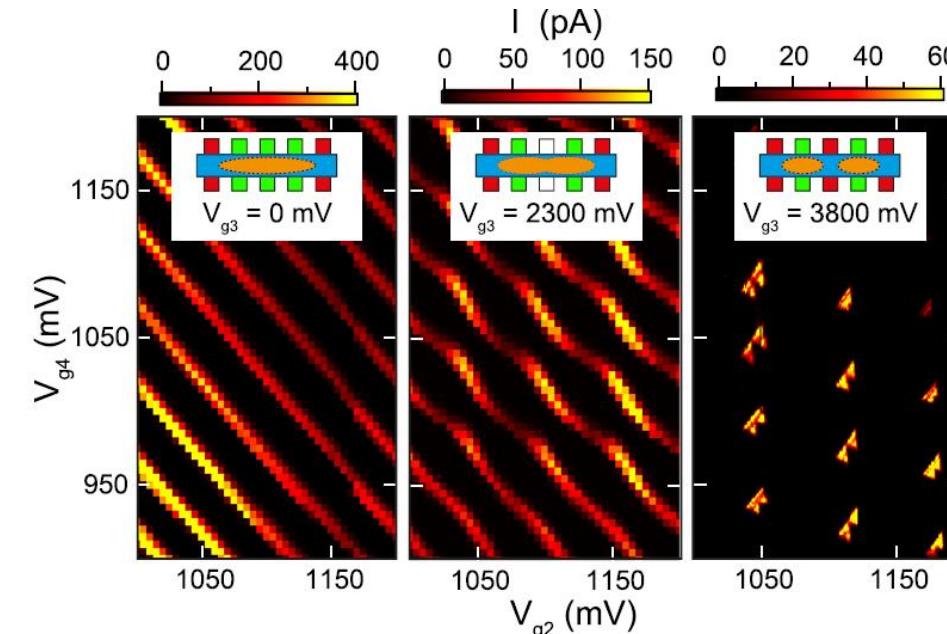
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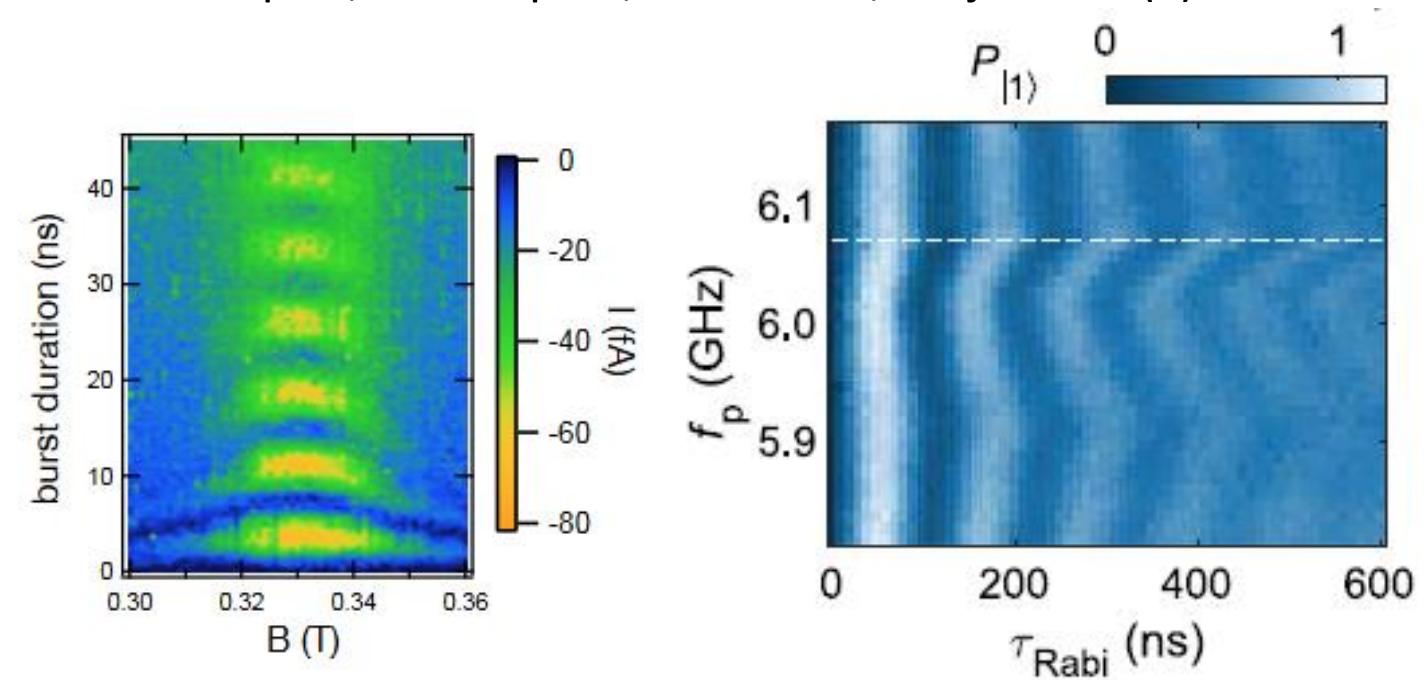
Radio frequency reflectometry techniques enable high bandwidth readout of semiconductor quantum dots. Careful impedance matching of the resonant circuit is required to achieve high sensitivity, which however proves challenging at cryogenic temperatures. Gallium arsenide-based voltage-tunable capacitors, so-called varactor diodes, can be used for in-situ tuning of the circuit impedance but deteriorate and fail at temperatures below 10 K and in magnetic fields. Here, we investigate a varactor based on strontium titanate with hyperabrupt capacitance-voltage characteristic, that is, a capacitance tunability similar to the best gallium arsenide-based devices. The varactor design introduced here is compact, scalable and easy to wirebond with an accessible capacitance range from 45 pF to 3.2 pF. We tune a resonant inductor-capacitor circuit to perfect impedance matching and observe robust, temperature and field independent matching down to 11 mK and up to 2 T in-plane field. Finally, we perform gate-dispersive charge sensing on a germanium/silicon core/shell nanowire hole double quantum dot, paving the way towards gate-based single-shot spin readout. Our results bring small, magnetic field-resilient, highly tunable varactors to mK temperatures, expanding the toolbox of cryo-radio frequency applications.

Ge/Si Core/Shell Nanowire Quantum Dots & Qubits



Why these Nanowires?

- Excellent gate-control of QD-formation^[1-3]
- Very strong SOI^[2] ($l_{SO} \sim 4 \text{ nm}$ vs. $l_{SO} \sim 31 \text{ nm}$ in FinFETs^[4])
- All-electric tunability of: l_{SO} , g , f_{Rabi} , T_2^{Echo}
- Ultrafast $f_{Rabi} \sim 435 \text{ MHz}$ @ $f_{Larmor} \sim 3.4 \text{ GHz}$
-> Strong driving: breakdown of RWA (?)
- Anisotropies, Sweetspots, Gatemon, Majoranas (?) etc.



Measuring Ge/Si Nanowire QDs

Here: Gate-Dispersive Reflectometry with surface-mount inductors
& perfect impedance matching at mK Temperatures and in B-field

Eggli, Svab et al. [arXiv:2303.02933v1](https://arxiv.org/abs/2303.02933v1)

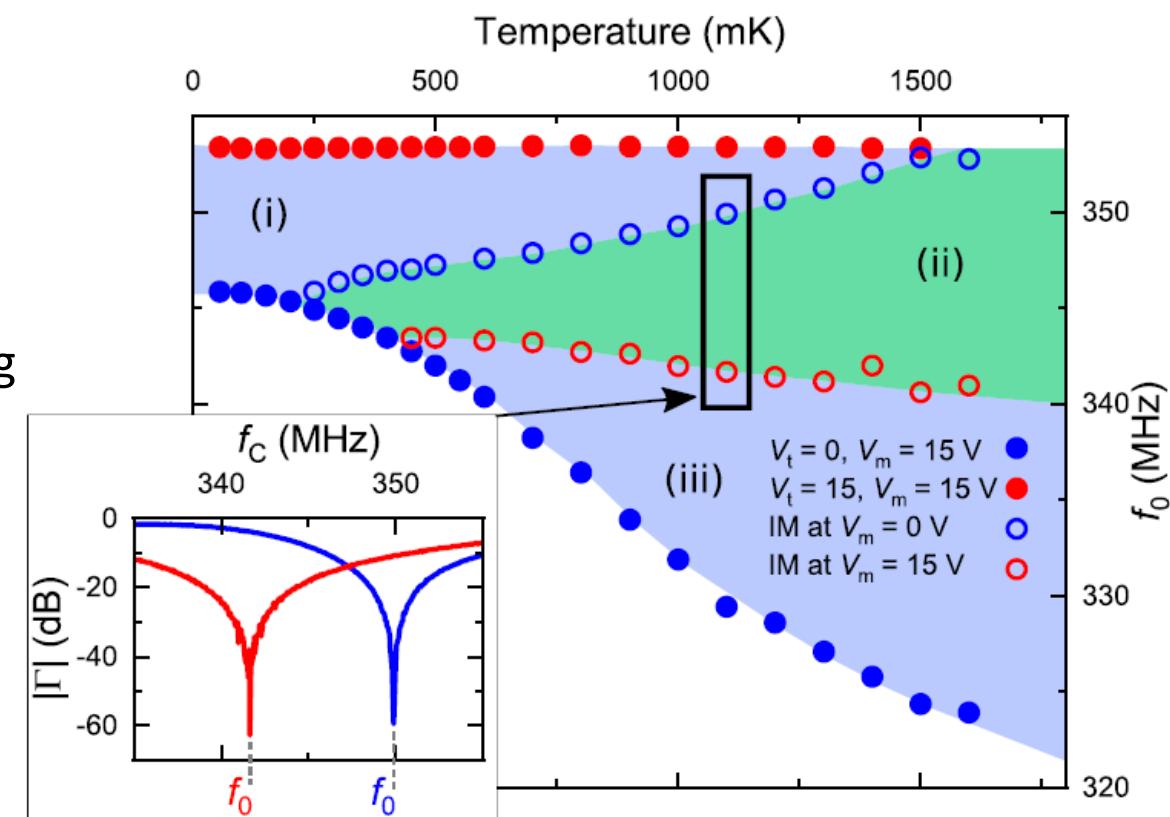
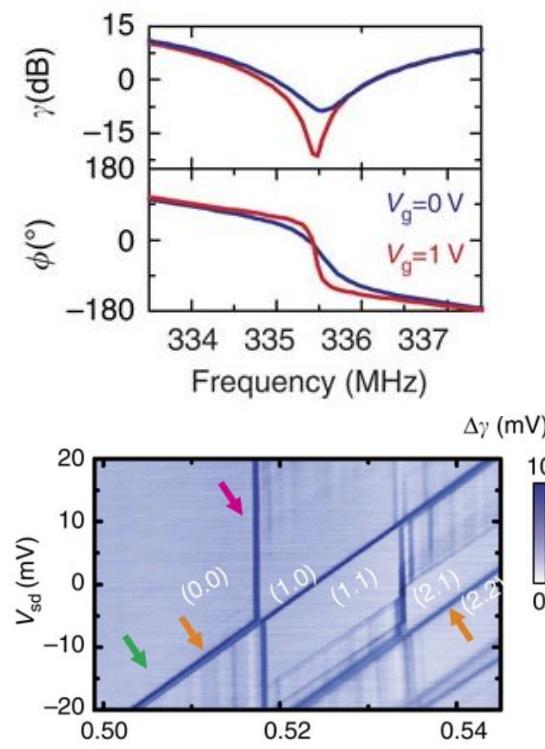
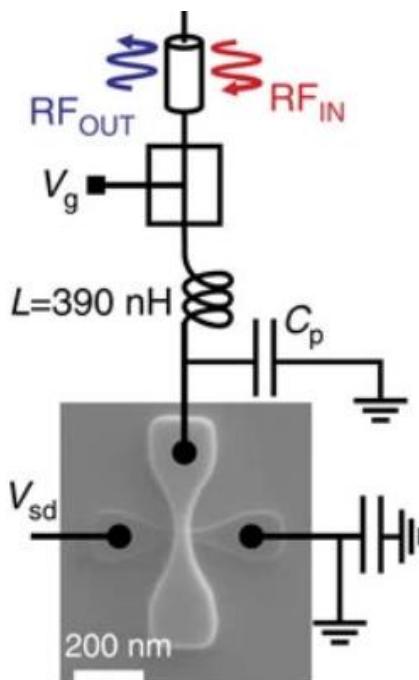
Reflectometry and Impedance Matching

Fundamental problem of high-bandwidth measurements:

- Quantum devices: $Z(T) \geq \frac{h}{e^2} = 25.8 \text{ k}\Omega$ to $\sim M\Omega$
- Standard RF-electronics: $Z_0 = 50 \Omega$

-> LC-resonator for downconversion

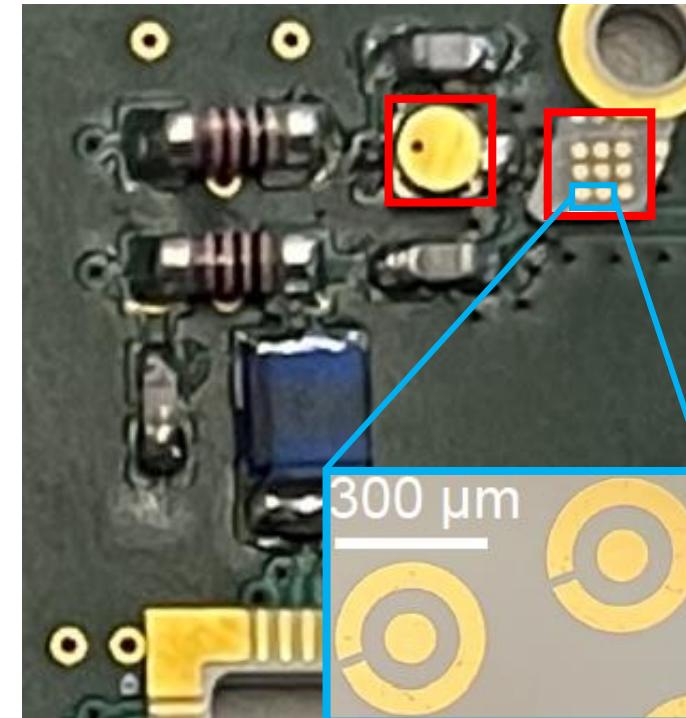
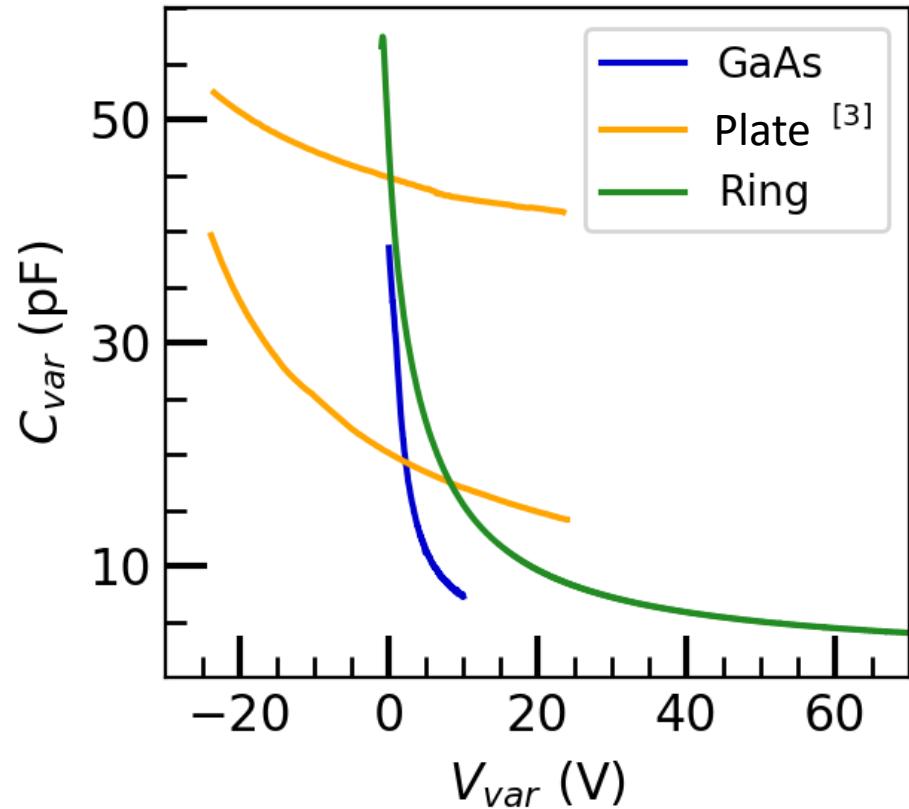
-> Voltage-tunable capacitor(s) (**varactor**) for in-situ tuning



Problems with GaAs-varactors:

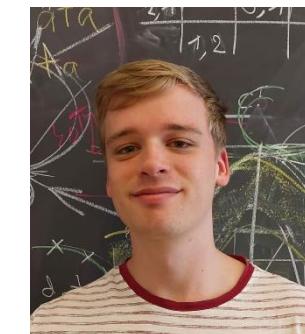
- Freezing-out of diode
- Susceptible to magnetic fields

Strontium Titanate Varactors



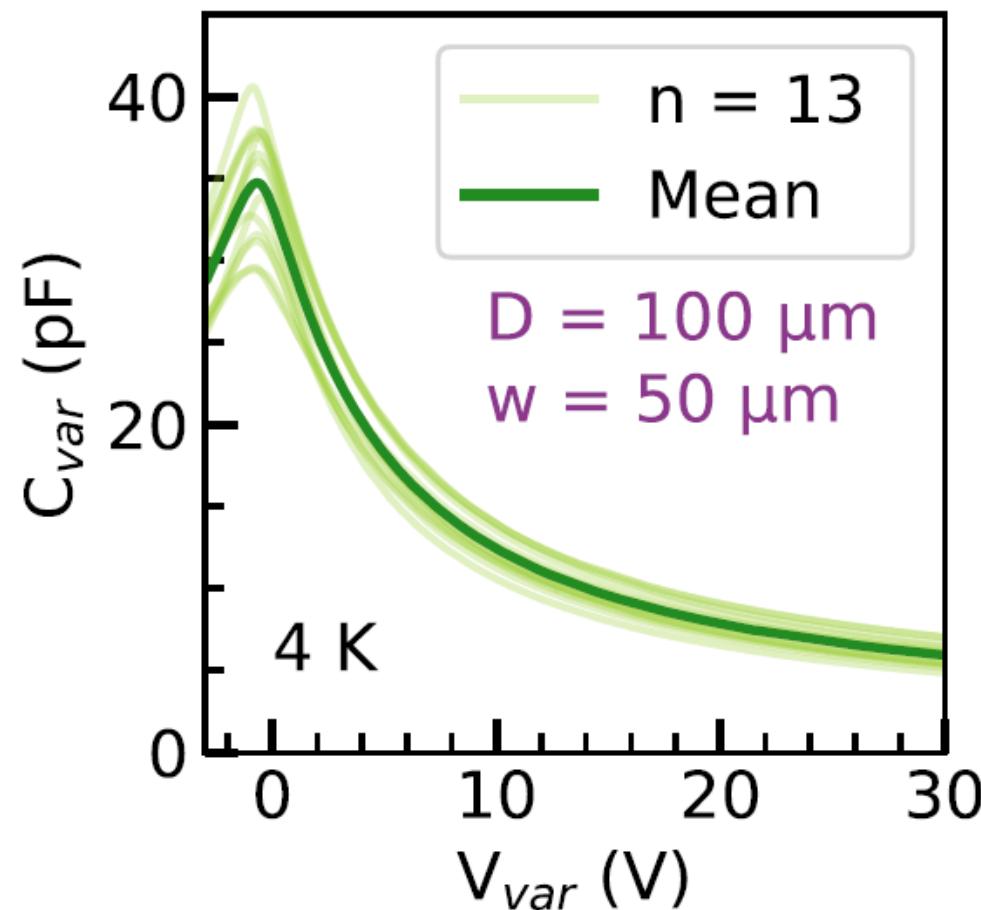
Anisotropic dielectric constant below 10 K:
 $\varepsilon_{r,(111)} \sim 12'000$ $\varepsilon_{r,(001)} \sim 24'000$
Highly tunable by large electric fields
-> **Voltage-tunable capacitor**

The engineering challenge:
Small C_{max} (≤ 50 pF)
Large fields in the crystal ($\sim 500 \frac{V}{mm}$)



Dominique Trüssel

Varactor Performance

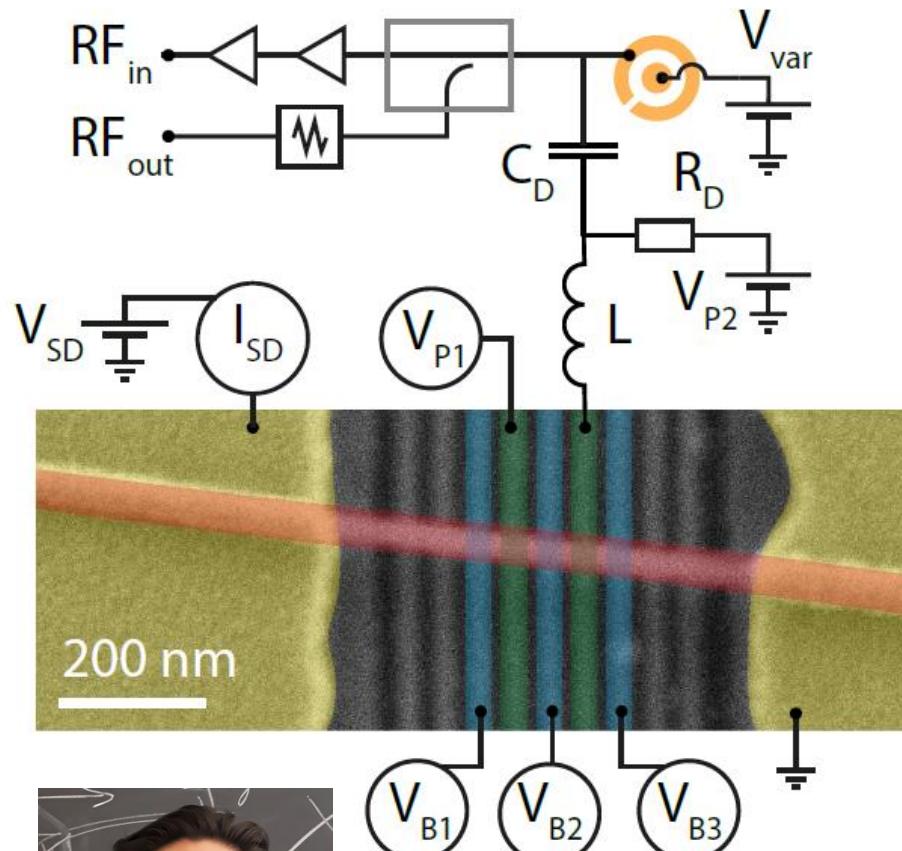


$$C_{var}(V_{var}) = \frac{K}{(V_{var} + \Phi_{diode})^\gamma}$$

Hyperabrupt varactors:
 $\gamma > 0.5$

Tuning range:
 $V_{var} = 0 - 100 \text{ V} \leftrightarrow 45 - 3.2 \text{ pF}$

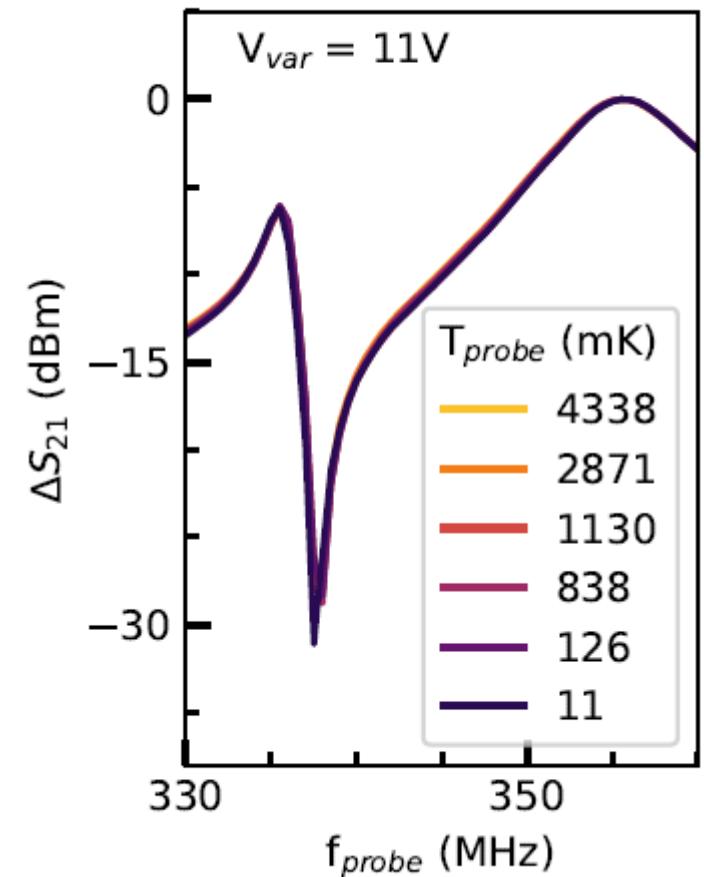
Perfect Impedance Matching at 15 mK



Ge/Si core/shell nanowire
quantum dot device

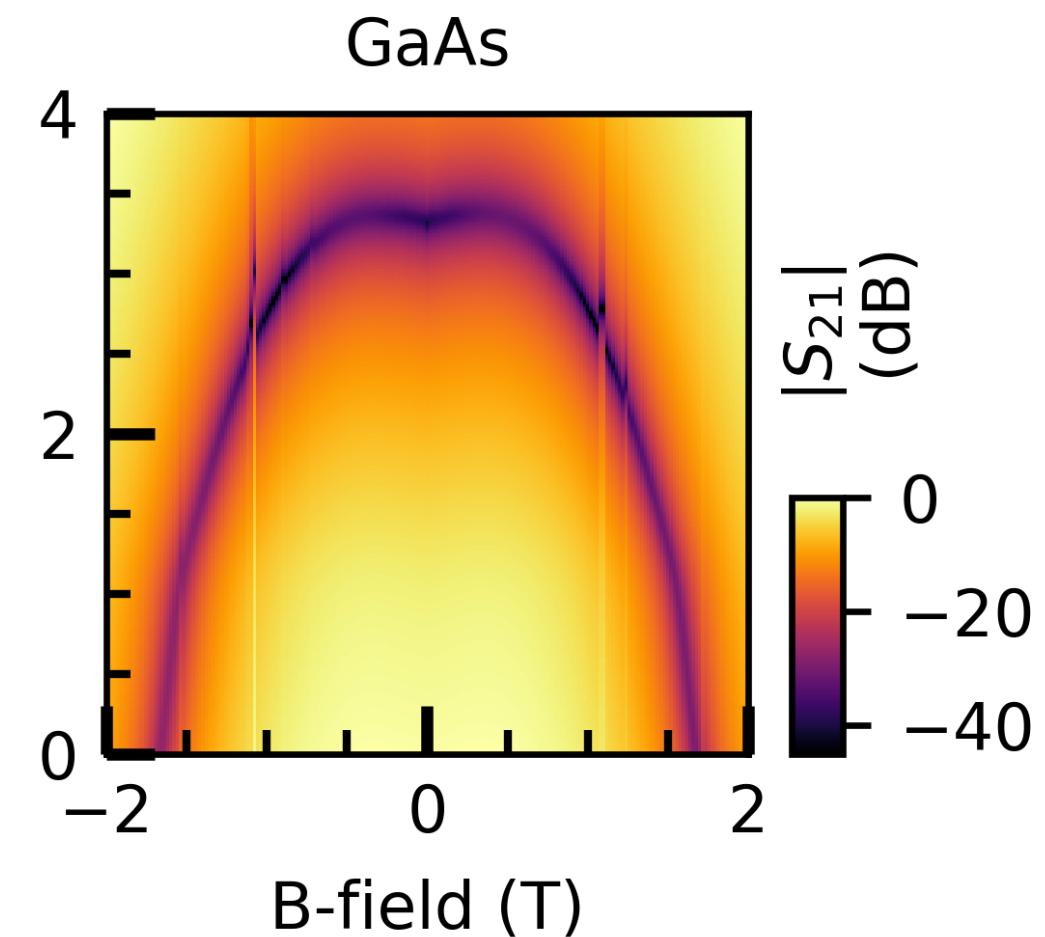
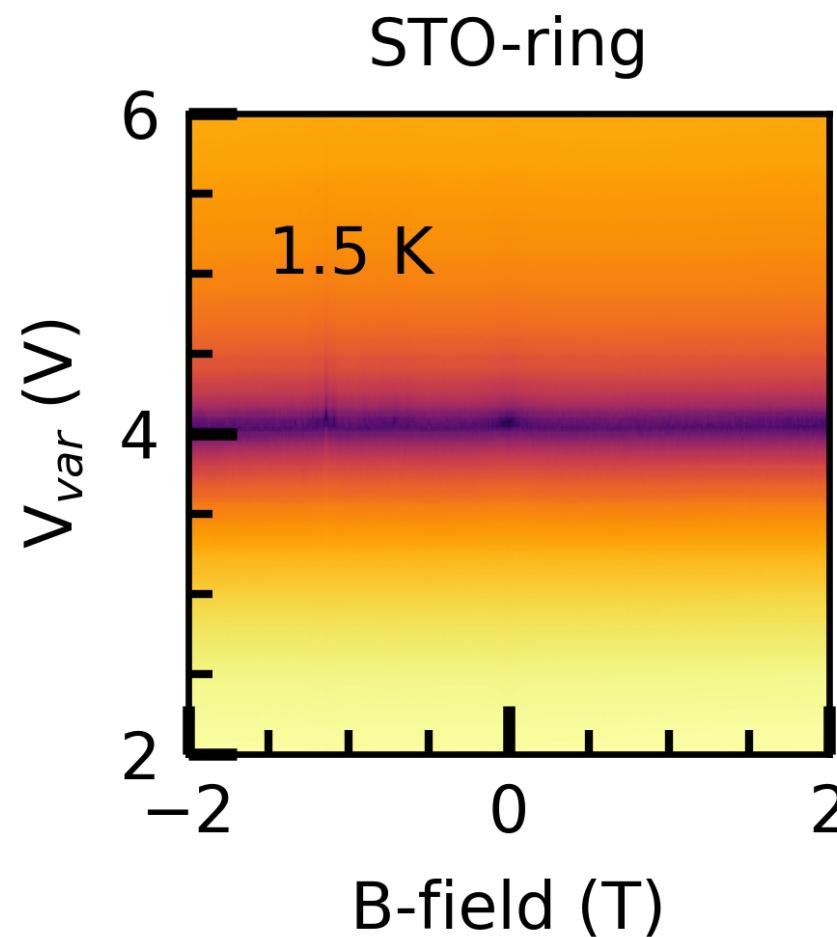
Simon Svab

Perfect impedance matching:
• moderate V_{var}
• only 1 varactor

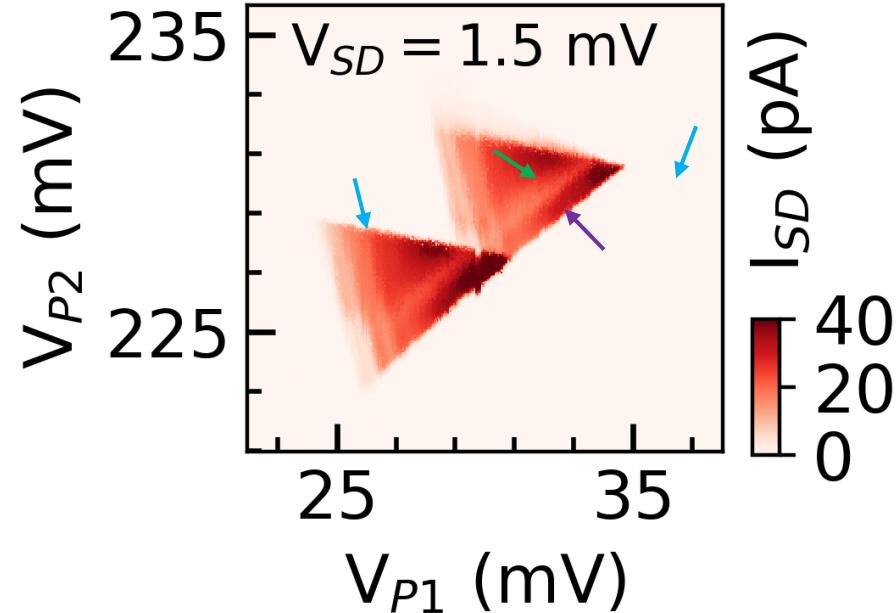


Highly resilient to
temperature-changes

Field-Resilience of Matching with STO



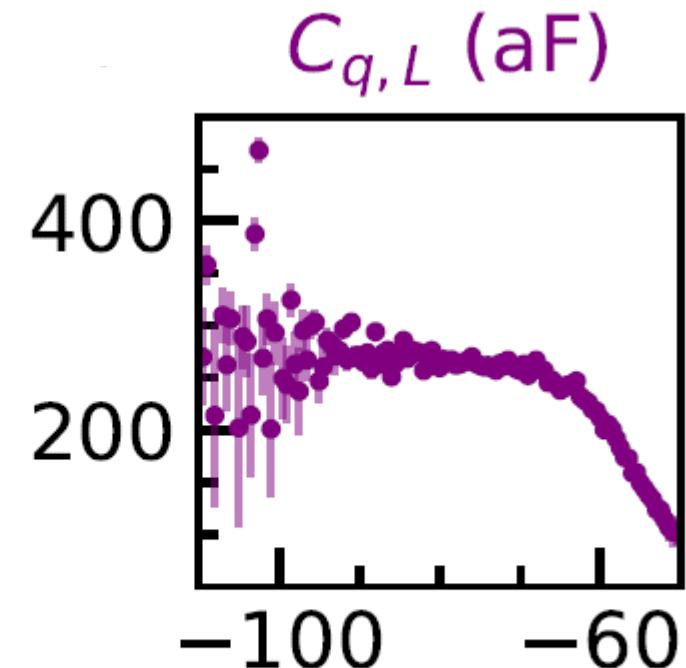
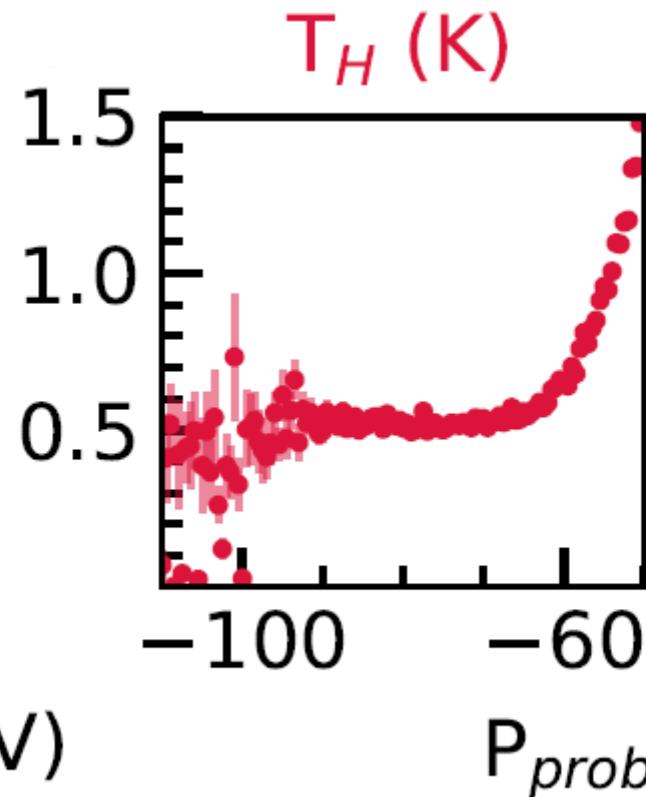
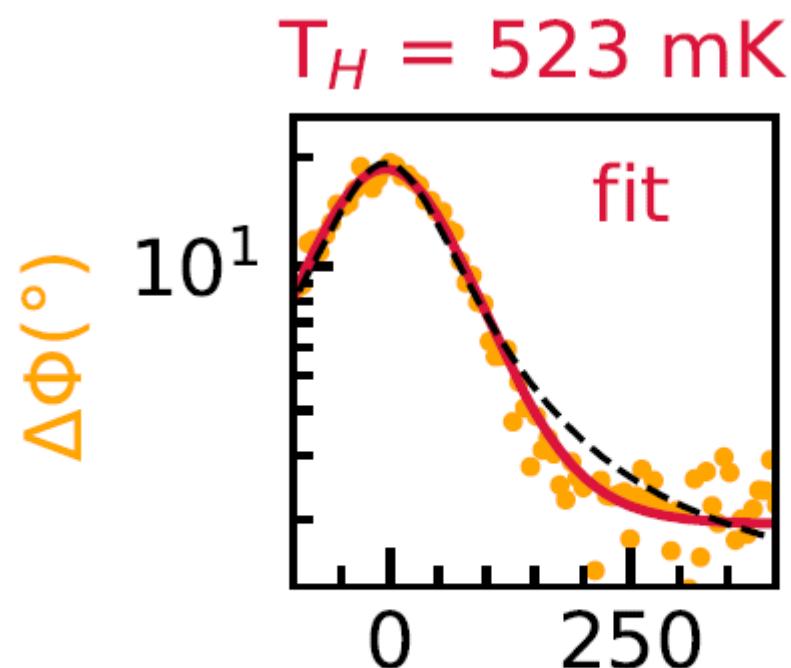
Charge Sensing



Bias triangles in DC
current: DQD

Interdot transition coincides with triangle baseline
Lead transitions of right dot
Faint excited state signature

Lineshape Fitting: Lead Transition

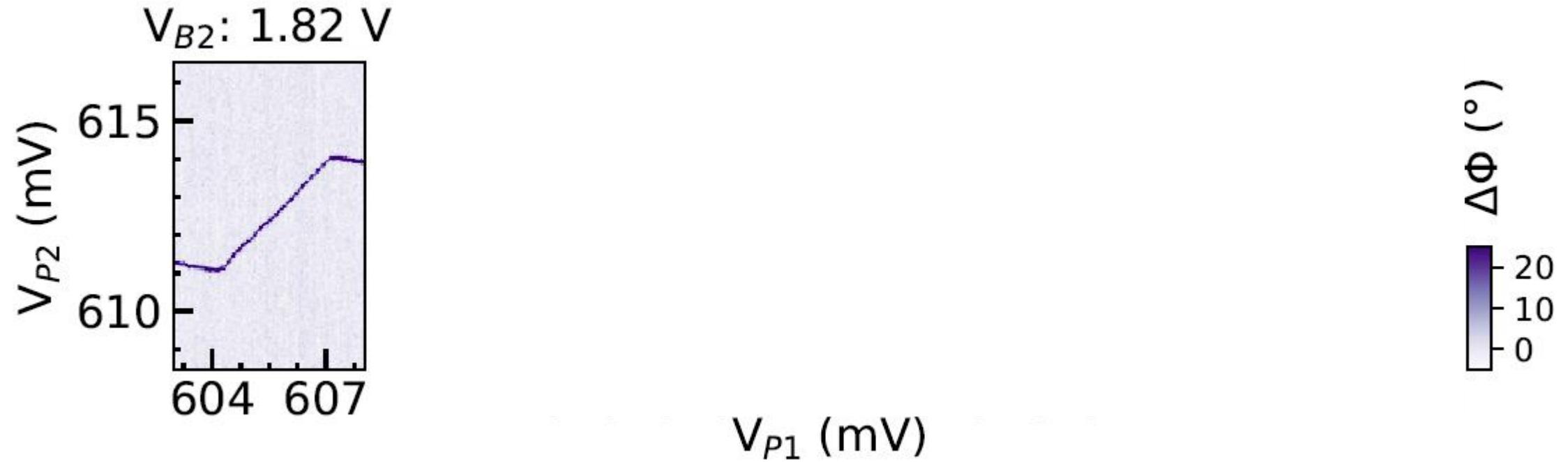


$$\Delta\Phi = \Delta\Phi_{max} \cdot \cosh^{-2} \left(\frac{\alpha_{P1}(V_{P1} - V_{P1_0})}{2k_B T_H} \right)$$

$$T_H \approx (520 \pm 20) \text{ mK}$$

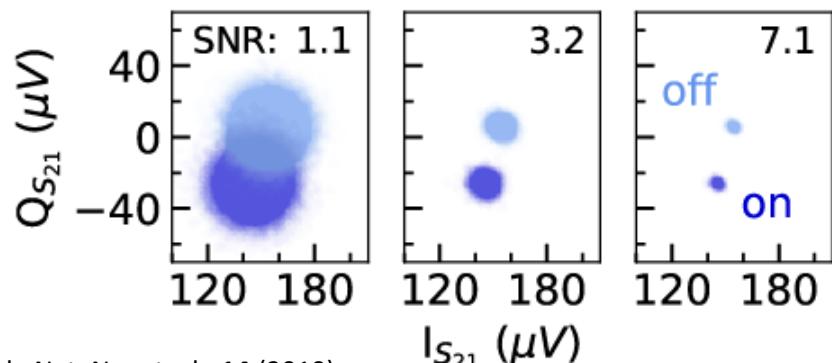
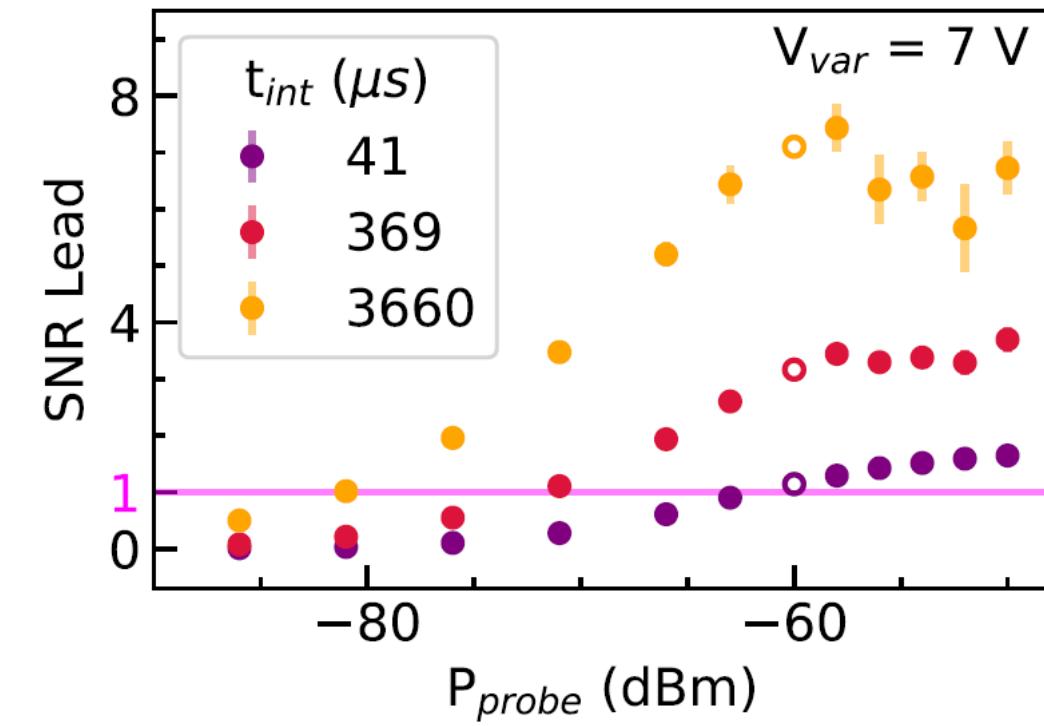
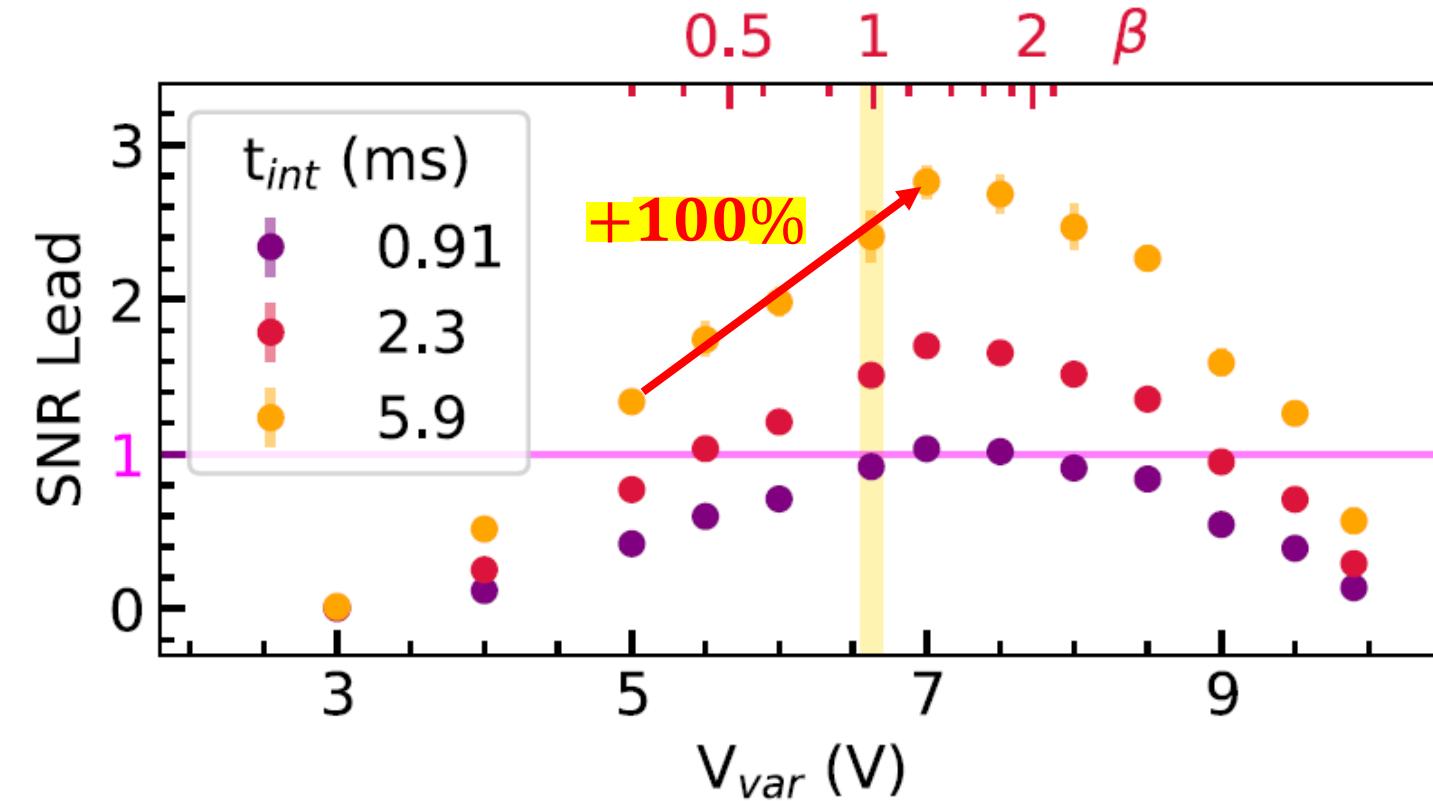
$$C_{q,L} = (266 \pm 8) \text{ aF}$$

Tuning the Interdot Tunnel-Coupling



Selective control over interdot-tunnel rate

Impact of Impedance Matching on SNR

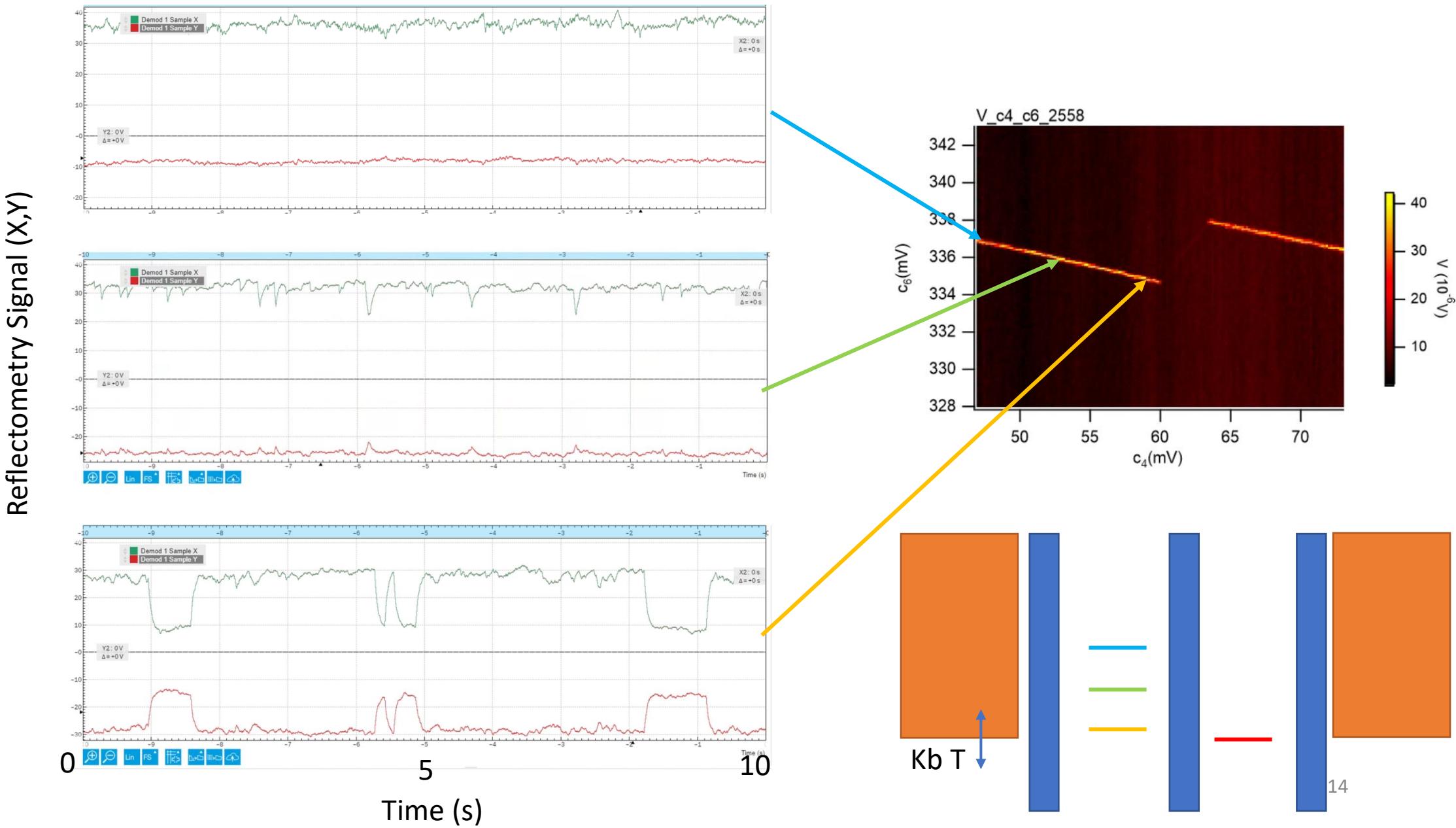


Time-Domain SNR of charge transitions^[1]

Signal boost by matching: $\Delta V_{var} = 2V \leftrightarrow \Delta C_{var} = 4 pF$

At higher power: $SNR = 1.1$ for $t_{int} = 41 \mu s$

Outlook: Real-Time Charge Sensing



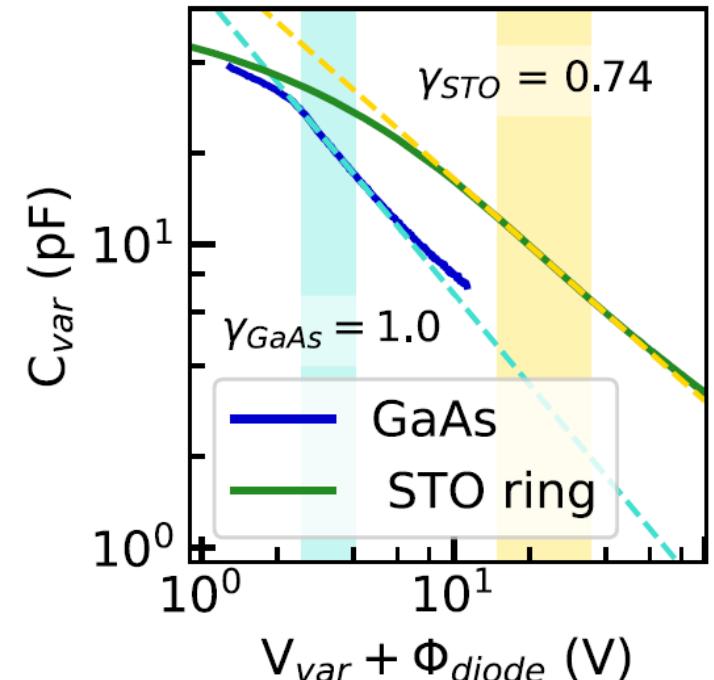
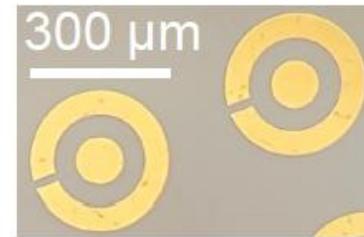
Conclusions & Outlook

Compact hyperabrupt STO varactor:

- Resilient to magnetic field & cryogenic temperatures

-> More complex matching networks (multiplexing)

-> Matching with NbTiN high Q-inductors



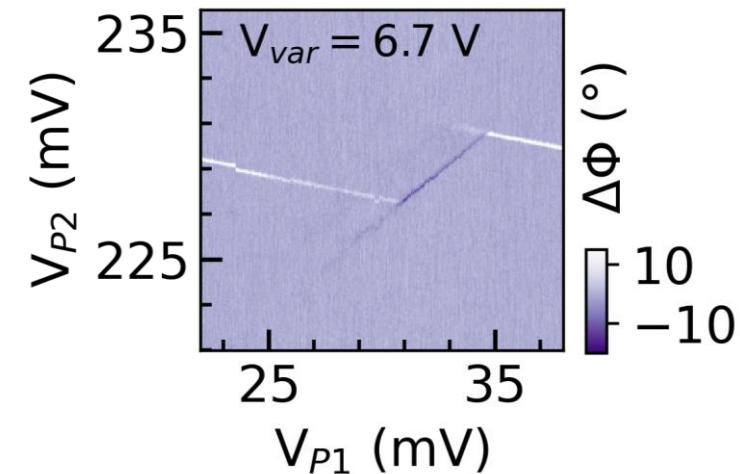
Gate-dispersive charge sensing with a Ge/Si nanowire DQD:

- Significant SNR-gains by optimisation of impedance matching

-> Last hole: currently >50 holes!

-> Short enough t_{int} : single-shot spin readout

-> T_1 , 2-qubit gate benchmarking, scaling

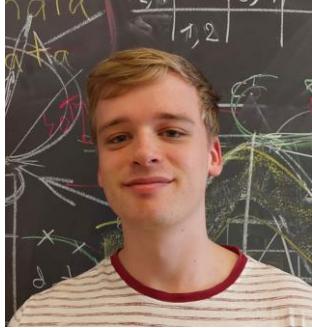


Acknowledgments

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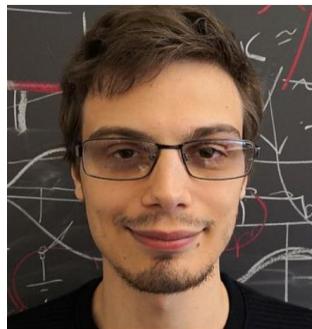
Nanowire growth:
Erik Bakkers & group



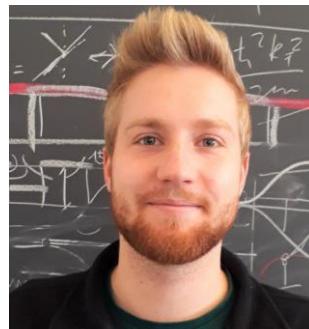
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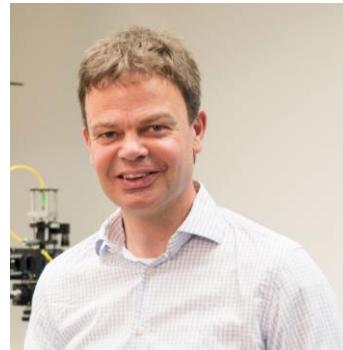
Miguel J. Carballido



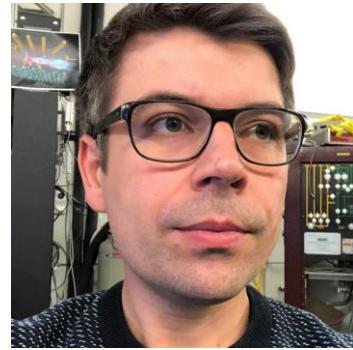
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Simon Geyer



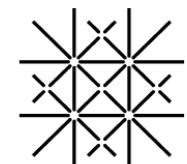
Richard Warburton



Andreas Kuhlmann



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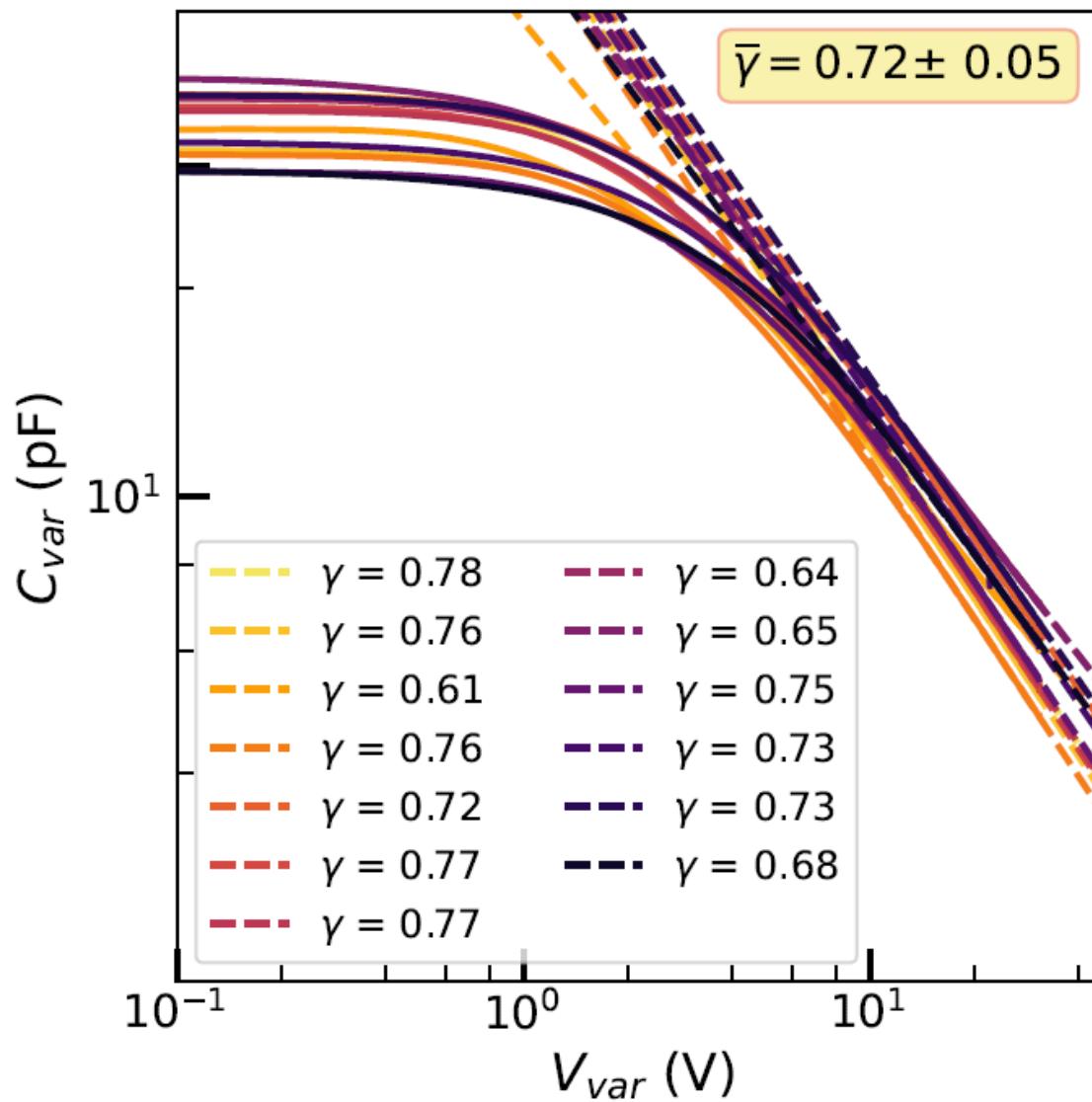


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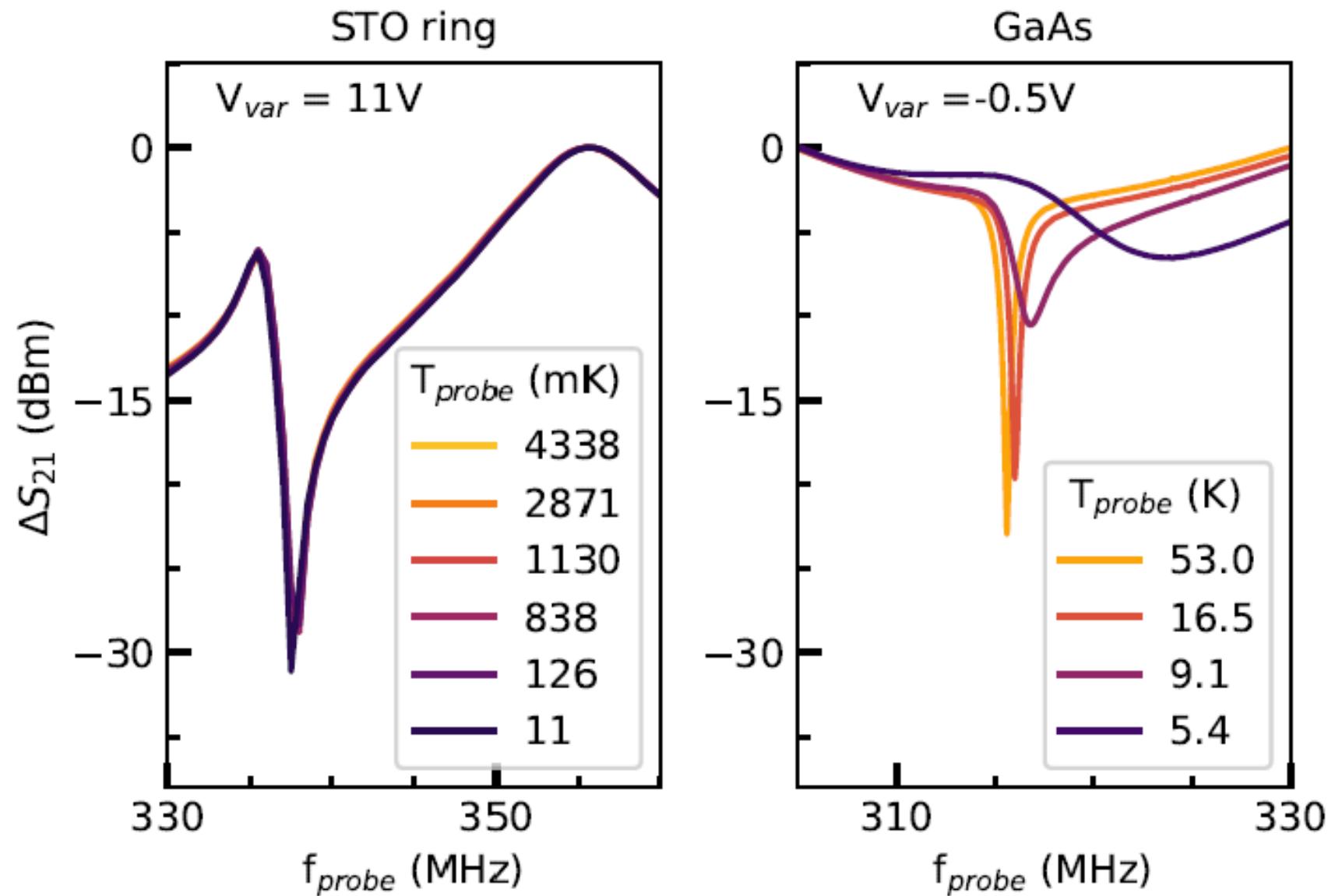


Thanks for your attention!

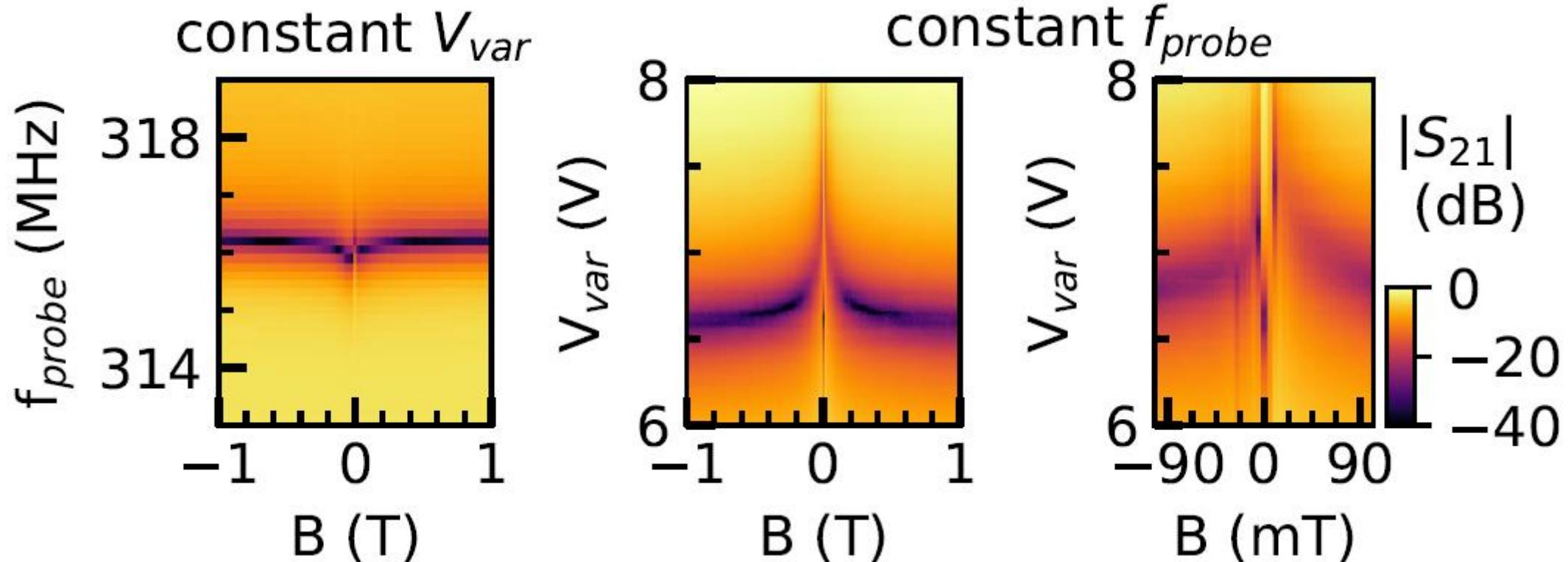
Consistent Hyperabrupticity



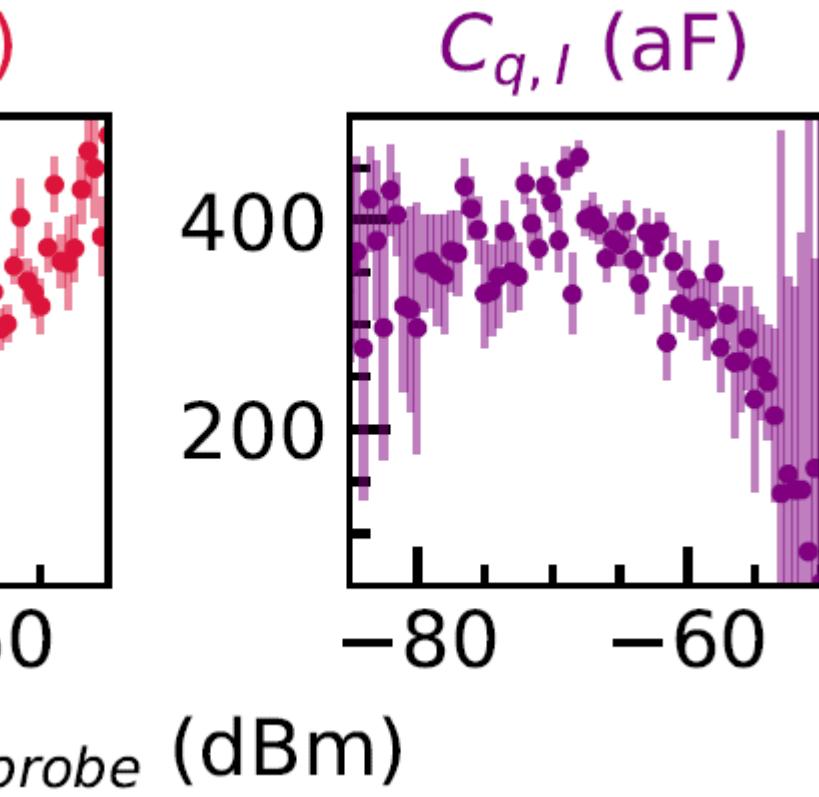
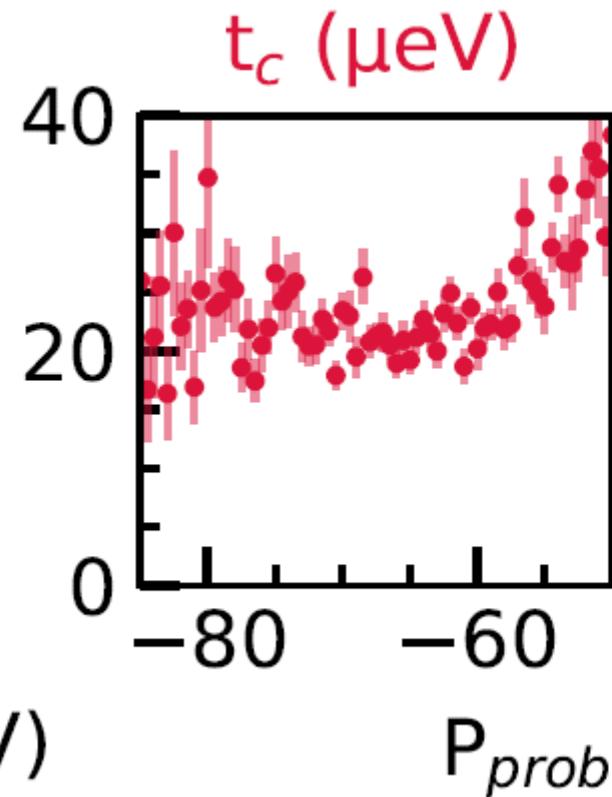
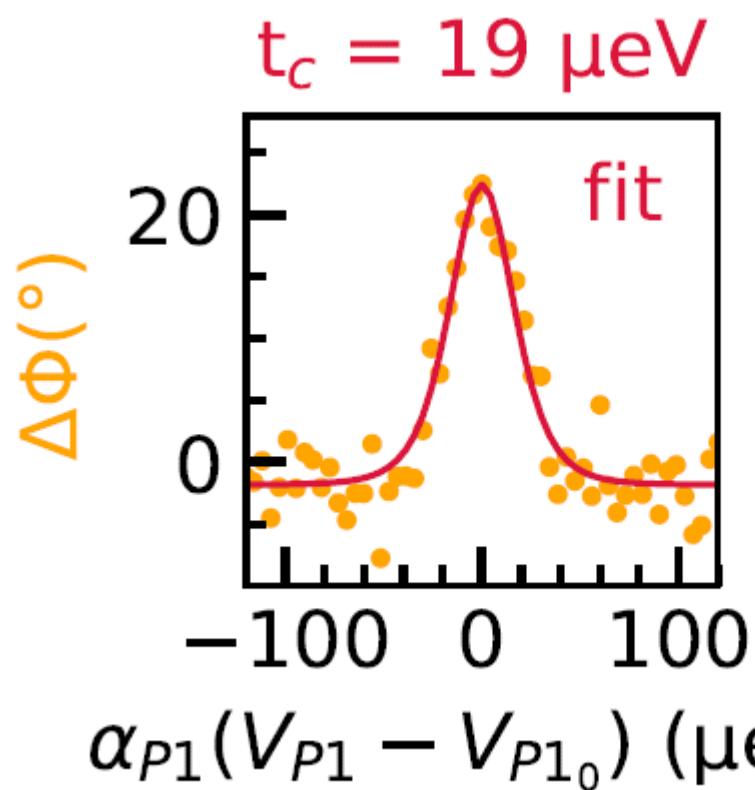
Temperature-dependence: GaAs vs STO



Zero-Field Anomaly at mK



Lineshape Fitting: Interdot Transition



$$\Delta\Phi = \Phi_0 \cdot t_c^2 \left(\left(\frac{\alpha_{P1}(V_{P1} - V_{P1_0})}{2\sqrt{2}} \right)^2 + t_c^2 \right)^{-3/2}$$

$$t_c \approx (22 \pm 5) \quad C_{q,I} \approx (380 \pm 70) \text{ aF}$$

Large-Scale Charge Stability Map

